## Beyond regular polyhedra: evolutionary prediction and experimental highpressure synthesis of SiOS

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SiOS represents a ternary generalization of the wellknown and highly important family of binary AB2 compounds including CO<sub>2</sub>, SiO<sub>2</sub>, GeO<sub>2</sub>, CS<sub>2</sub>, SiS<sub>2</sub>, etc. The presence of two different bond lengths suggests that its crystal structures may be different from those found in SiO<sub>2</sub> and SiS<sub>2</sub>. We applied evolutionary search based on DFT ab initio calculations to determine crystal structures of SiOS for pressures up to 100 GPa. We predicted the SiOS phase diagram at zero temperature and examined the structural, electronic and vibrational properties of the stable phases. At low pressure the stable phase is a tetrahedrally coordinated layered orthorhombic Cmc2, structure. This is predicted to transform at 16 GPa to one of two phases with only marginal enthalpy difference: an octahedrally coordinated layered monoclinic C2/m structure similar to the P-3m1 phase of SiS2 or nonlayered octahedrally coordinated tetragonal P42/mmc. The system remains insulating up to 100 GPa with band gap above 1.4 eV. Following the theoretical prediction we synthesized SiOS by laser heating elemental Si, O and S in the diamond anvil cell at pressure of 8 GPa. The observed XRD pattern is in very good agreement with the theoretical prediction for the Cmc2<sub>1</sub> structure.

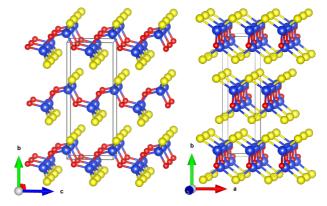


Figure 1: Layered tetrahedral Cmc2<sub>1</sub> structure of SiOS stable at low pressures

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